

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	1	("6200873").PN.	US-PGPUB; USPAT	OR	OFF	2005/04/02 11:08
L2	0	1 and (high adj aspect)	US-PGPUB; USPAT	OR	OFF	2005/04/02 11:40
L3	1	("6689220").PN.	US-PGPUB; USPAT	OR	OFF	2005/04/02 11:40
L4	0	3 and radical	US-PGPUB; USPAT	OR	ON	2005/04/02 11:40
S1	196	((aluminum adj oxide) "al.sub.2 o. sub.3") with ald	US-PGPUB; USPAT	OR	OFF	2005/04/01 13:19
S2	2862	((438/243-249) or (257/301-305)).CCLS.	US-PGPUB; USPAT	OR	OFF	2005/04/01 17:53
S3	6	S1 and S2	US-PGPUB; USPAT	OR	OFF	2005/04/01 13:18
S4	269	(jennifer near2 kennedy).xa.	US-PGPUB; USPAT	OR	OFF	2005/04/01 13:18
S5	2	S4 and S1	US-PGPUB; USPAT	OR	OFF	2005/04/01 13:18
S6	117686	((aluminum adj oxide) "al.sub.2 o. sub.3")	US-PGPUB; USPAT	OR	OFF	2005/04/01 17:23
S7	23	S4 and S6	US-PGPUB; USPAT	OR	OFF	2005/04/01 13:24
S8	206	S6 and S2	US-PGPUB; USPAT	OR	OFF	2005/04/01 13:33
S9	1	10/765052	US-PGPUB; USPAT	OR	OFF	2005/04/01 13:34
S10	1	S9 and ceramic	US-PGPUB; USPAT	OR	OFF	2005/04/01 13:55
S11	1	S9 and softening	US-PGPUB; USPAT	OR	OFF	2005/04/01 13:57
S12	0	collar with softening with resist	US-PGPUB; USPAT	OR	OFF	2005/04/01 13:57
S13	1	collar with soften\$ with resist	US-PGPUB; USPAT	OR	OFF	2005/04/01 14:01
S14	1	("6777303").PN.	US-PGPUB; USPAT	OR	OFF	2005/04/01 14:01
S15	1	S14 and burning	US-PGPUB; USPAT	OR	OFF	2005/04/01 14:02
S16	1	S14 and burn	US-PGPUB; USPAT	OR	OFF	2005/04/01 14:24
S17	6	S2 and (ald with ((silicon adj nitride) "si.sub.3 N.sub.4"))	US-PGPUB; USPAT	OR	OFF	2005/04/01 14:41
S18	114	(ald with ((silicon adj nitride) "si. sub.3 N.sub.4"))	US-PGPUB; USPAT	OR	OFF	2005/04/01 16:16

S19	104	(photoresist with fill\$) and (oxide with collar)	US-PGPUB; USPAT	OR	OFF	2005/04/01 16:17
S20	105	(photoresist with fill\$) and (oxide with collar)	US-PGPUB; USPAT	OR	ON	2005/04/01 16:17
S21	65	S20 and S2	US-PGPUB; USPAT	OR	ON	2005/04/01 16:17
S22	1	("6200873").PN.	US-PGPUB; USPAT	OR	OFF	2005/04/01 17:23
S23	0	((aluminum adj oxide) "al.sub.2 o. sub.3") and S22	US-PGPUB; USPAT	OR	OFF	2005/04/01 17:28
S24	0	(photoresist adj instead near2 polysilicon) with (suitable)	US-PGPUB; USPAT	OR	OFF	2005/04/01 17:29
S25	0	(photoresist adj instead near2 polysilicon) with (suitable)	US-PGPUB; USPAT	OR	OFF	2005/04/01 17:29
S26	0	(photoresist near instead near2 polysilicon) with (suitable)	US-PGPUB; USPAT	OR	OFF	2005/04/01 17:29
S27	0	(photoresist near instead near2 polysilicon) with (suitable)	US-PGPUB; USPAT	OR	ON	2005/04/01 17:30
S28	0	(photoresist with instead with polysilicon) with (suitable)	US-PGPUB; USPAT	OR	ON	2005/04/01 17:31
S29	0	(photoresist with instead with polysilicon) with (suitable)	US-PGPUB; USPAT	OR	ON	2005/04/01 17:31
S30	1	("6200873").PN.	US-PGPUB; USPAT	OR	OFF	2005/04/01 17:31
S31	0	(photoresist with instead with polysilicon) with (suitable) and S30	US-PGPUB; USPAT	OR	ON	2005/04/01 17:31
S32	0	(another adj suitable adj filling adj material)	US-PGPUB; USPAT	OR	ON	2005/04/01 17:32
S33	0	(another adj suitable adj filling adj material)	US-PGPUB; USPAT	OR	ON	2005/04/01 17:32
S34	0	(another adj suitable adj filling adj material)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/01 17:32
S35	0	(another adj2 suitable adj2 filling adj2 material)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/01 17:33
S36	2862	((438/243-249) or (257/301-305)).CCLS.	US-PGPUB; USPAT	OR	OFF	2005/04/01 17:53
S37	424	(photoresist with filling with material)	US-PGPUB; USPAT	OR	OFF	2005/04/01 17:53

S38	473	(photoresist with filling with material)	US-PGPUB; USPAT	OR	ON	2005/04/01 17:53
S39	18	S36 and S38	US-PGPUB; USPAT	OR	ON	2005/04/01 17:59
S40	66	ald with radical with plasma	US-PGPUB; USPAT	OR	ON	2005/04/01 18:02
S41	0	S40 and S36	US-PGPUB; USPAT	OR	ON	2005/04/01 18:01
S42	2	ald with radical with plasma with (improv\$ advantag\$ benefit\$)	US-PGPUB; USPAT	OR	ON	2005/04/01 18:01
S43	0	ald with radical with plasma with ((silicon adj oxide) "sio.sub.2")	US-PGPUB; USPAT	OR	ON	2005/04/01 18:02
S44	0	(ald with radical with plasma) same ((silicon adj oxide) "sio.sub.2")	US-PGPUB; USPAT	OR	ON	2005/04/01 18:03
S45	53	(ald with plasma) same ((silicon adj oxide) "sio.sub.2")	US-PGPUB; USPAT	OR	ON	2005/04/01 18:06
S46	0	((ald with plasma) with (advantag\$ benefit\$ improv\$)) same ((silicon adj oxide) "sio.sub.2")	US-PGPUB; USPAT	OR	ON	2005/04/01 18:04
S47	29	((ald with plasma) with (advantag\$ benefit\$ improv\$))	US-PGPUB; USPAT	OR	ON	2005/04/01 18:04
S48	15	S47 and ((silicon adj oxide) "sio.sub.2")	US-PGPUB; USPAT	OR	ON	2005/04/01 18:06